

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 10/615,051
Filing Date July 7, 2003
Confirmation No. 7998
Inventor Brian A. Vaartstra
Assignee Micron Technology, Inc.
Group Art Unit 2823
Examiner Brook Kebede
Attorney's Docket No. MI22-2308
Customer No. 021567
Title: Methods of Forming a Phosphorus Doped Silicon Dioxide Comprising
Layer

RESPONSE TO JULY 13, 2005 NOTICE OF ALLOWANCE
PRELIMINARY AMENDMENT TO ACCOMPANY RCE FILING

To: Mail Stop RCE
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

VIA U.S. EXPRESS MAIL

From: Mark S. Matkin (Tel. 509-624-4276; Fax 509-838-3424)
Wells St. John P.S.
601 West First Avenue, Suite 1300
Spokane, WA 99201-3828

Responsive to the Notice of Allowance dated July 13, 2005, Applicant
amends and remarks as follows:

AMENDMENTS

EV633265452